March 19, 2026

Company name: RS Technologies Co., Ltd.
Name of representative: Nagayoshi Ho,
(Securities code: 3445; Prime Market)
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Notice on the Establishment of a Subsidiary in China

RS Technologies Co., Ltd. (hereinafter "RST") hereby announces that its consolidated subsidiary in China, GRINM Semiconductor Material Co., Ltd. (hereinafter "GRITEK"), resolved at a meeting of its Board of Directors held today to establish a subsidiary tentatively named Guojing Semiconductor Materials (Baotou) Co., Ltd. in the Inner Mongolia Autonomous Region of China, as outlined below.

1. Purpose of Establishment

With the aim of entering the prime wafer manufacturing and sales business in China, RST made GRITEK a consolidated subsidiary through M & A in January 2018. In August of the same year, RST and GRITEK established Shandong GRIMN Semiconductor Materials Co., Ltd. ("Shandong GRITEK") as a joint venture, with the newly constructed main plant in Shandong Province, focusing on the manufacture and sale of 8-inch prime wafers.

The subsidiary plans to construct a single crystal plant to produce single crystals of silicon wafers as well as large-diameter single crystals for consumable parts used in etching equipment for semiconductors. RST has decided to establish a new subsidiary based on the judgment that it is expected to further improve its production capacity and strengthen its competitiveness by collaborating with GRITEK.

As for the location of the subsidiary, Baotou City was selected because utilities cost is reasonable compared to the cities of Beijing and Dezhou, where we are currently based.

Specific investment and business plans will be disclosed as soon as they are determined.

2． Outline of the newly established subsidiary Guojing Semiconductor Materials (Baotou) Co., Ltd. (tentative name)

(1) Name	Guojing Semiconductor Materials (Baotou) Co., Ltd. (tentative name) *1	
(2) Address	Inner Mongolia Baotouqiao New Technology Industrial Development Area, China	
(3) Name and Title of Representative	Chairperson Zhang Gohu	
(4) Business Description	Manufacturing and sales of single-crystal silicon and large-diameter single-crystal silicon	
(5) Capital *2	RMB 400 million (approximately ¥9,084 million) *3	
(6) Equity ratio	GRITEK：100%	
(7) Date of Establishment	April 2026 (planned)	
(8) Relationship between the listed company and the company	Capital relationship	GRITEK will hold 100% shares
	Personnel relationship	Officers and employees from RST will serve as directors.
	Business relationship	Not applicable.

*1. We will apply for the above trade name to Chinese authorities

*2. The capital will be paid in stages according to the contract schedule.

*3. Converted at 1 RMB=22.71JPY

3． Overview of investment company

【 About GRINM Semiconductor Material Co., Ltd. （GRITEK） 】

(1) Name	GRINM Semiconductor Material Co., Ltd.	
(2) Address	No.2 Outer Avenue, Xicheng District, Beijing, People's Republic of China	
(3) Name and Title of Representative	Chairperson, Nagayoshi Ho	
(4) Business Description	Manufacture, sale and development of silicon wafers, CZ ingots and FZ ingots, development of related technologies, etc.	
(5) Capital	1.25 billion RMB (as of the end of December 2025)	
(6) Date of Establishment	June 21, 2001 (GRITEK became a consolidated subsidiary of RST in January 2018)	
(7) Relationship between the listed company and the company	Capital relationship	RST owns total 40.85% of the shares directly and indirectly
	Personnel relationship	RST's directors and employees concurrently serve as directors

	Business relationship	Not applicable

4. Impact on Business Results

The impact on consolidated financial results for FY2026 is expected to be minor. We will promptly inform you of any matters that need to be made public in the future.